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# Magnon Torque Transferred into a Magnetic Insulator through an Antiferromagnetic Insulator

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**Abstract:** Electrical spin-orbit torque (SOT) in magnetic insulators (MI) has been intensively studied due to its advantages in spin-orbitronic devices with ultralow energy consumption. However, the magnon torque in the MIs, which has the potential to further lower the energy consumption, still remains elusive. In this work, we demonstrate the efficient magnon torque transferred into an MI through an antiferromagnetic insulator. By fabricating a Pt/NiO/Tm<sub>3</sub>Fe<sub>5</sub>O<sub>12</sub> heterostructure with different NiO thicknesses, we have systematically investigated the evolution of the transferred magnon torque. We show that the magnon torque efficiency transferred through the NiO into the MI can retain a high value (~50%), which is comparable to the previous report for the magnon torque transferred into the metallic magnet. Our study manifests the feasibility of realizing the pure magnon-based spin-orbitronic devices with ultralow energy consumption and high efficiency.

Keywords: magnon torque; magnetic insulator; antiferromagnetic insulator; spin-orbit torque

# 1. Introduction

Discovering novel phenomena and functionalities originating from the spin-orbit coupling (SOC) is an emerging direction in spin-orbitronics [1-4]. In the spin-orbitronic devices, a pure spin current is generated from a charge current through the SOC, defined as electrical spin current, which can be transferred into a magnet, and works as electrical spin-orbit torque (SOT) to effectively manipulate its magnetization (see Figure 1a) [5–7]. By now, the electrical SOT has been intensively studied due to its essential role in the spinorbitronic technology [8–10]. Recently, another class of the spin current, defined as magnon current, has emerged and attracted much attention [11–14]. For the magnon current, the spin angular momentum is carried by the precessing spin moments, which does not request movement of the electrons (see Figure 1b). Therefore, the Joule heat dissipation can be drastically reduced in the magnon-based spin-orbitronic devices. Very recently, Wang et al. reported the successful observation of the magnon torque transferred into a metallic magnet through an antiferromagnetic insulator, and they realized the magnetization switching of the metallic magnet by the magnon torque [13]. On the other hand, it has been known that the electrical SOT can be transferred into a magnetic insulator (MI) and drive its magnetization [15–18]. Therefore, it is natural to ask whether the magnon torque can be efficiently transferred into the MI, since it may provide a practical approach to further lower the energy dissipation in the spin-orbitronic devices. To study the magnon torque in the MI is important in both fundamental and practical aspects of spin-orbitronics.



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**Figure 1.** Schematic of the MI magnetization manipulated by (**a**) the electrical SOT via the electrical spin current  $J_s$ , and (**b**) the magnon torque via the magnon current  $J_M$ .

In this work, we study the magnon torque transferred into the  $Tm_3Fe_5O_{12}$  (TmIG), a typical MI. By fabricating the Pt/NiO/TmIG heterostruture with different NiO thicknesses, we systematically investigate the evolution of the transferred magnon torque. We show that the magnon torque efficiency transferred through the NiO into the MI can retain a high value, which is comparable to the previous report for the magnon torque transferred into the metallic magnet.

## 2. Materials and Methods

For the sample fabrication, a 4-nm-thick TmIG film was deposited on  $Gd_3Sc_2Ga_3O_{12}$  (GSGG) (111) single crystal substrates at 700 °C by magnetron sputtering. After cooling down to the room temperature, NiO films with thicknesses from 0 to 30 nm were deposited on the TmIG surface, and then a 4-nm-thick Pt film was deposited on the NiO surface. All the films were deposited without breaking the vacuum. The base pressure in the chamber before deposition was better than  $1 \times 10^{-6}$  Pa, and the deposition pressure was 0.4 Pa. The film thickness was controlled by the deposition time with a precalibrated deposition rate. All the measurements were conducted at room temperature.

#### 3. Results and Discussion

The anomalous Hall effect (AHE) was measured by patterning the Pt/NiO/TmIG films into Hall bar devices, as shown in Figure 2a. A constant charge current was injected into the films along the *x*-axis, and the Hall voltage was measured by sweeping an external magnetic field  $H_z$  along the z-axis. Figure 2b exhibits the AHE resistance  $R_{\rm H}$  curves of the Pt (4 nm)/NiO (t nm)/TmIG (4 nm) devices with different NiO thicknesses. In the case of t = 0 nm,  $R_{\rm H}$  is obtained as about 1.7 m $\Omega$ . By increasing t to 0.6 nm,  $R_{\rm H}$  drastically decreases to about 0.5 m $\Omega$ . In the Pt/TmIG heterostructure, the anomalous Hall signal attributes to both the proximity-induced ferromagnetism of Pt and the spin current [19]. Therefore, although the TmIG is an insulator, the proximity-induced ferromagnetic layer in Pt can generate an AHE signal as normal ferromagnetic conductors do. Simultaneously, the spin current via the nonzero imaginary part of the spin-mixing conductance can also generate an AHE-like signal at the Pt/TmIG interface. By inserting the 0.6-nm-thick NiO layer, the proximity effect is eliminated. Furthermore, the ultrathin NiO layer without antiferromagnetic ordering only acts as an insulator, which prevents the spin transportation from the Pt to the TmIG layer. Both effects result in this drastic decrease of the AHE resistance. However, by further increasing the NiO thickness, although the proximity effect is completely eliminated, we still can observe the AHE signal. This is because, by increasing the NiO thickness, the long-range antiferromagnetic order restores, and then the magnon current can transport through the antiferromagnetic NiO layer [13]. As shown in Figure 2c, the AHE resistance curve of the Pt (4 nm)/NiO (10 nm)/TmIG (4 nm) device unambiguously confirms the magnon current transferred into the TmIG layer through the NiO layer.



**Figure 2.** (a) Schematic of the setup for the AHE resistance measurement. (b) AHE resistance curves of the Pt (4 nm)/NiO (*t* nm)/TmIG (4 nm) devices with different NiO thicknesses. (c) AHE resistance curve of the Pt (4 nm)/NiO (10 nm)/TmIG (4 nm) device.

In the following, we measure the damping-like torque-induced effective field  $H_z^{\text{eff}}$  in the Pt (4 nm)/NiO (t nm)/TmIG (4 nm) devices with different NiO thicknesses. An external magnetic field along the z-axis  $H_z$  was swept to measure the AHE with a constant external magnetic field along the x-axis  $H_x$ , as shown in Figure 2a. In the Néel-type domain walls, the damping-like torque works as an additional effective field along the z-axis, which favors one type of the domain [20,21]. This results in a horizontal shift of the AHE hysteresis loop. Figure 3a-c presents typical shifted hysteresis loops of the devices with different NiO thicknesses. By applying a positive current, the hysteresis loop shifts to the left, which is vice versa for a negative current. By measuring the current-induced shift  $H_z^{\text{eff}}$ , the magnitude of the damping-like torque can be determined. Here, we define the dampinglike SOT generation efficiency  $\chi$  as  $\chi = H_z^{\text{eff}}/J_e$ , where  $J_e$  is the applied current density. The corresponding  $H_x$  dependence of  $\chi$  are summarized in Figure 3d–f, respectively. First,  $\chi$ gradually increases with  $H_x$  and then saturates at a large in-plane field  $H_x^{sat}$ .  $H_x^{sat}$  represents the minimum field to overcome the effective Dzyaloshinskii-Moriya interaction (DMI) field  $H_{\text{DMI}}$ . Therefore, we can obtain the maximum SOT efficiency  $\chi_{\text{sat}} = 2.1 \times 10^{-10} \text{ Oe A}^{-1} \text{ m}^2$ and  $H_{\text{DMI}} \approx 120$  Oe for NiO = 0 nm. For NiO = 1.8 nm,  $\chi_{\text{sat}} = 0.75 \times 10^{-10}$  Oe A<sup>-1</sup> m<sup>2</sup> and  $H_{\text{DMI}} \approx 100$  Oe are obtained. For NiO = 3 nm,  $\chi_{\text{sat}} = 1.1 \times 10^{-10}$  Oe A<sup>-1</sup> m<sup>2</sup> and  $H_{\rm DMI} \approx 125$  Oe are obtained. This result shows that  $\chi_{\rm sat}$  changes nonmonotonically with the NiO thickness.



**Figure 3.** AHE resistance curves of the Pt (4 nm)/NiO (*t* nm)/TmIG (4 nm) devices by sweeping  $H_z$  with (a) t = 0 nm and  $H_x = 200$  Oe, (b) t = 1.8 nm and  $H_x = 500$  Oe, (c) t = 3 nm and  $H_x = 200$  Oe. Slight vertical offsets for both AHE loops are introduced for clarity. Corresponding  $H_x$  dependence of the SOT efficiency  $\chi$  for (d) t = 0 nm, (e) t = 1.8 nm and (f) t = 3 nm.  $\chi_{sat}$  is the maximum SOT efficiency, and  $H_{DMI}$  is the field that  $\chi$  saturates.

Figure 4 summarizes the NiO thickness dependence of  $\chi_{sat}$ . It can be seen that  $\chi_{\text{sat}}$  drastically decreases by increasing the NiO thickness to 1.8 nm. In this range, the antiferromagnetic ordering is weak due to the ultrathin NiO thickness, and the magnon torque only plays a minor role. The SOT in this range is due to the electron spin tunneling effect through the insulator. Above 1.8 nm,  $\chi_{sat}$  starts to increase, which unambiguously confirms the presence of the magnon torque, since the magnons in the NiO are the only spin-angular-momentum carriers. We also fabricated and measured the Pt  $(4 \text{ nm})/\text{SiO}_2$ (t nm)/TmIG (4 nm) devices for comparison. When SiO<sub>2</sub> thickness is below 1.8 nm, it shows a similar decrease due to the electron spin tunneling effect, and no signal can be detected above 1.8 nm. For the Pt (4 nm)/NiO (t nm)/TmIG (4 nm) devices, a peak value of  $\chi_{sat}$  is obtained at t = 3 nm, which is about 50% of that for the Pt/TmIG device. Wang et al. reported the magnon torque transferred into the metallic magnet, and the peak value is about 45% of that for the control devices without NiO [13]. Our study demonstrates that the magnon torque transferred trough the NiO into the MI can also retain a high efficiency. By further increasing the NiO thickness up to 10 nm, the magnon torque generation can still be detected, although it gradually decreases due to the energy dissipation caused by magnon-magnon and magnon-phonon coupling. A previous study demonstrates that the spin fluctuation in the NiO layer can increase the spin conductivity [22]. Since the spin fluctuation can be enhanced near the Néel temperature, an enhancement of the SOT generation can be expected near the Néel temperature. In our study, in order to determine the Néel temperature, we measured the temperature dependence of the coercivity  $H_c$  for t = 1.8, 3 and 4.2 nm, respectively. When the temperature is below the Néel temperature, an abrupt enhancement is expected to occur due to the presence of the ferromagneticantiferromagnetic interaction [23]. As shown in the inset of Figure 4, the Néel temperature is about 250 K for t = 1.8 nm, 300 K for t = 3 nm and 325 K for t = 4.2 nm. Therefore, the sharp peak of  $\chi_{sat}$  at t = 3 nm is attributed to the enhancement of the spin fluctuations in the NiO layer.

We notice that in Wang et al.'s study, the peak value of the magnon torque efficiency appears when the NiO thickness is 25 nm, which is thicker than that in our study (3 nm) [13]. This could be caused by the different NiO quality grown with different deposition conditions.



**Figure 4.** The dependence of the maximum SOT efficiency  $\chi_{sat}$  on the NiO thickness. Pt (4 nm)/SiO<sub>2</sub> (*t* nm)/TmIG (4 nm) devices were measured for comparison. The inset shows the temperature dependence of the coercivity  $H_c$  for the Pt (4 nm)/SiO<sub>2</sub> (*t* nm)/TmIG (4 nm) devices.

## 4. Conclusions

In summary, we have demonstrated the magnon torque transferred into an MI through an antiferromagnetic insulator. By fabricating the Pt/NiO/TmIG heterostructure with different NiO thicknesses, we have systematically investigated the evolution of the magnon torque efficiency. We show that the magnon torque transferred through the NiO into the MI can retain about 50%, which is comparable to the previous report for the magnon torque transferred into the metallic magnet. Our study manifests the feasibility of realizing the pure magnon-based spintronic devices with ultralow energy consumption and high efficiency.

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#### References

- Sinova, J.; Valenzuela, S.O.; Wunderlich, J.; Back, C.H.; Jungwirth, T. Spin Hall effects. *Rev. Mod. Phys.* 2015, 87, 1213–1260. [CrossRef]
- 2. Jungwirth, T.; Wunderlich, J.; Olejnik, K. Spin Hall effect devices. Nat. Mater. 2012, 11, 382–390. [CrossRef]
- Manchon, A.; Koo, H.C.; Nitta, J.; Frolov, S.M.; Duine, R.A. New perspectives for Rashba spin-orbit coupling. *Nat. Mater.* 2015, 14, 871–882. [CrossRef] [PubMed]

- 4. Soumyanarayanan, A.; Reyren, N.; Fert, A.; Panagopoulos, C. Emergent phenomena induced by spin–orbit coupling at surfaces and interfaces. *Nature* **2016**, *539*, 509–517. [CrossRef]
- 5. Manchon, A.; Železný, J.; Miron, I.M.; Jungwirth, T.; Sinova, J.; Thiaville, A.; Garello, K.; Gambardella, P. Current-induced spin-orbit torques in ferromagnetic and antiferromagnetic systems. *Rev. Mod. Phys.* **2019**, *91*, 035004. [CrossRef]
- 6. Liu, L.; Pai, C.F.; Li, Y.; Tseng, H.W.; Ralph, D.C.; Buhrman, R.A. Spin-torque switching with the giant spin Hall effect of tantalum. *Science* 2012, 336, 555–558. [CrossRef] [PubMed]
- Miron, I.M.; Garello, K.; Gaudin, G.; Zermatten, P.J.; Costache, M.V.; Auffret, S.; Bandiera, S.; Rodmacq, B.; Schuhl, A.; Gambardella, P. Perpendicular switching of a single ferromagnetic layer induced by in-plane current injection. *Nature* 2011, 476, 189–193. [CrossRef]
- 8. Garello, K.; Miron, I.M.; Avci, C.O.; Freimuth, F.; Mokrousov, Y.; Blügel, S.; Auffret, S.; Boulle, O.; Gaudin, G.; Gambardella, P. Symmetry and magnitude of spin–orbit torques in ferromagnetic heterostructures. *Nat. Nanotechnol.* **2013**, *8*, 587. [CrossRef]
- Fan, X.; Wu, J.; Chen, Y.; Jerry, M.J.; Zhang, H.; Xiao, J.Q. Observation of the nonlocal spin-orbital effective field. *Nat. Commun.* 2013, 4, 1–7. [CrossRef]
- Kim, J.; Sinha, J.; Hayashi, M.; Yamanouchi, M.; Fukami, S.; Suzuki, T.; Mitani, S.; Ohno, H. Layer thickness dependence of the current-induced effective field vector in Ta|CoFeB|MgO. *Nat. Mater.* 2013, 12, 240–245. [CrossRef]
- 11. Takei, S.; Moriyama, T.; Ono, T.; Tserkovnyak, Y. Antiferromagnet-mediated spin transfer between a metal and a ferromagnet. *Phys. Rev. B* 2015, *92*, 020409. [CrossRef]
- 12. Rezende, S.; Rodríguez-Suárez, R.; Azevedo, A. Diffusive magnonic spin transport in antiferromagnetic insulators. *Phys. Rev. B* **2016**, *93*, 054412. [CrossRef]
- 13. Wang, Y.; Zhu, D.; Yang, Y.; Lee, K.; Mishra, R.; Go, G.; Oh, S.H.; Kim, D.H.; Cai, K.; Liu, E.; et al. Magnetization switching by magnon-mediated spin torque through an antiferromagnetic insulator. *Science* **2019**, *366*, 1125–1128. [CrossRef]
- Suresh, A.; Bajpai, U.; Petrović, M.D.; Yang, H.; Nikolić, B.K. Magnon-versus Electron-Mediated Spin-Transfer Torque Exerted by Spin Current across an Antiferromagnetic Insulator to Switch the Magnetization of an Adjacent Ferromagnetic Metal. *Phys. Rev. Appl.* 2021, 15, 034089. [CrossRef]
- 15. Avci, C.O.; Quindeau, A.; Pai, C.F.; Mann, M.; Caretta, L.; Tang, A.S.; Onbasli, M.C.; Ross, C.A.; Beach, G.S. Current-induced switching in a magnetic insulator. *Nat. Mater.* **2017**, *16*, 309–314. [CrossRef]
- 16. Shao, Q.; Tang, C.; Yu, G.; Navabi, A.; Wu, H.; He, C.; Li, J.; Upadhyaya, P.; Zhang, P.; Razavi, S.A.; et al. Role of dimensional crossover on spin-orbit torque efficiency in magnetic insulator thin films. *Nat. Commun.* **2018**, *9*, 3612. [CrossRef]
- 17. Guo, C.; Wan, C.; Zhao, M.; Wu, H.; Fang, C.; Yan, Z.; Feng, J.; Liu, H.; Han, X. Spin-orbit torque switching in perpendicular Y<sub>3</sub>Fe<sub>5</sub>O<sub>12</sub>/Pt bilayer. *Appl. Phys. Lett.* **2019**, *114*, 192409. [CrossRef]
- Liu, L.; Fan, Z.; Chen, Z.; Chen, Z.; Ye, Z.; Zheng, H.; Zeng, Q.; Jia, W.; Li, S.; Wang, N.; et al. Spin–orbit torques in heavy metal/ferrimagnetic insulator bilayers near compensation. *Appl. Phys. Lett.* 2021, 119, 052401. [CrossRef]
- 19. Tang, C.; Sellappan, P.; Liu, Y.; Xu, Y.; Garay, J.E.; Shi, J. Anomalous Hall hysteresis in Tm<sub>3</sub>Fe<sub>5</sub>O<sub>12</sub>/Pt with strain-induced perpendicular magnetic anisotropy. *Phys. Rev. B* **2016**, *94*, 140403. [CrossRef]
- 20. Pai, C.F.; Mann, M.; Tan, A.J.; Beach, G.S. Determination of spin torque efficiencies in heterostructures with perpendicular magnetic anisotropy. *Phys. Rev. B* 2016, *93*, 144409. [CrossRef]
- 21. Finley, J.; Liu, L. Spin-orbit-torque efficiency in compensated ferrimagnetic cobalt-terbium alloys. *Phys. Rev. Appl.* **2016**, *6*, 054001. [CrossRef]
- 22. Qiu, Z.; Li, J.; Hou, D.; Arenholz, E.; N'Diaye, A.T.; Tan, A.; Uchida, K.I.; Sato, K.; Okamoto, S.; Tserkovnyak, Y.; et al. Spin-current probe for phase transition in an insulator. *Nat. Commun.* **2016**, *7*, 12670. [CrossRef]
- Pan, C.; Gao, T.; Harumoto, T.; Zhang, Z.; Nakamura, Y.; Shi, J. Asymmetry in magnetic behavior caused by superposition of unidirectional and four-fold magnetic anisotropies in CoPt/FeMn bilayers. *Appl. Surf. Sci.* 2019, 480, 148–153. [CrossRef]